Electrical and Noise Modeling of GaAs Schottky Diode Mixers in the THz Band

Diego Pardo, Jesús Grajal, and Susana Pérez

Abstract—This paper presents a simulation tool for the analysis and design of Schottky mixers which is able to evaluate self-consistently both the conversion losses and the noise temperature. The tool is based on a Monte Carlo model of the diode coupled with a multi-tone harmonic balance technique. A remarkable feature of this tool is that it avoids the need of analytical or empirical models. The validation of the tool has been carried out by comparing simulation results with measurements of mixers published in the literature up to 2.5 THz. The usefulness of Schottky diodes as frequency mixers above 2.5 THz is analyzed. Additionally, the range of application and the limitations of simpler simulation tools based on lumped equivalent circuits or drift-diffusion models have been evaluated using the Monte Carlo model as a reference.

Index Terms—Drift-diffusion, frequency mixer, harmonic balance technique, lumped equivalent circuit (LEC), Monte Carlo, numerical modeling, Schottky diode, THz frequencies.

I. INTRODUCTION

HE development of sources and detectors at millimeter and submillimeter wavelengths has been mainly driven by applications in astronomy and space science [1]–[3]. In recent years, with terahertz technology becoming mature, new applications appear in different topics such as Earth observation, medical imaging, security, radar and communications, among others [1], [4].

GaAs Schottky diode technology has been widely used at millimeter and submillimeter wavelengths in the last decades due to the excellent trade-off between mobility and bandgap in GaAs, and also to the simplicity and maturity of GaAs processing [1]. The use of Schottky technology for receivers is getting popular for application such as Earth observation, planetary science and ground applications (medicine, security, etc.) [1], [4], [5]. Schottky mixers offer good enough sensitivities and performance for these applications, and do not need to be cooled,

Manuscript received February 17, 2015; revised July 07, 2015 and October 07, 2015; accepted November 05, 2015. Date of publication December 07, 2015; date of current version January 20, 2016. This work was supported by the European Commissionunder Project MIDAS FP7-SPACE-2009-1 242334), by the Spanish National Research and Development Program under Projects TEC2011-28683-C02-01, TEC2013-41640-R, TEC2014-53815-R, and TeraSense (Consolider-Ingenio 2010, CDS2008-00068), by the Madrid Regional Governmentunder project S2013/ICE-3000 (SPADERADAR-CM) and by the Junta de Castilla y Leónunder project SA052U13.

D. Pardo and J. Grajal are with the Signal, System and Radiocommunications Department, Universidad Politécnica de Madrid, E.T.S.I. Telecomunicación, Av. Complutense 30, 28040 Madrid, Spain (e-mail: dpardo@gmr.ssr.upm.es; jesus@gmr.ssr.upm.es).

S. Pérez is with the Applied Physics Department, Universidad de Salamanca, Plaza de la Merced s/n, 37008 Salamanca, Spain, (e-mail: susana@usal.es).

Color versions of one or more of the figures in this paper are available online at http://ieeexplore.ieee.org.

Digital Object Identifier 10.1109/TTHZ.2015.2502061

contrary to HEB and SIS mixers, with the subsequent reduction in system sizes and costs.

In order to effectively design Schottky mixers, both the electrical and noise performances of the devices have to be analyzed in a fully self-consistent manner. Most of the simulation tools used in the design of Schottky mixers are based on the conversion matrix (CM) formalism [6] where the diode is modeled analytically by a lumped equivalent circuit (LEC). LEC models do not take into account important physical effects within the semiconductor device, such as velocity saturation and nonlocal effects in time and space [7]–[13]. Hence, the use of LEC models has limited validity at high frequencies and power levels. As regards noise sources, simulation tools based on the CM usually take into account shot and thermal noise as well as the effects of the modulation of the noise sources by the LO excitation. However they present important deficiencies to describe the excess noise due to hot electrons and intervalley transfer that appears in the device under high field conditions [14], [15]. Circuit simulators based on physics-based models like drift-diffusion or hydrodynamic models have been developed, where noise can be evaluated with the transfer-impedance field method [16]-[19]. However, a fundamental limitation of these techniques is that they require to know the spectral performance of the noise sources, usually provided by Monte Carlo simulations.

The scope of this paper is to present a simulation tool which enables the analysis and design of Schottky mixers from both electrical and noise considerations, without the necessity of any additional analytical or empirical model. This tool is based on the multi-tone harmonic balance (HB) technique together with the Monte Carlo (MC) model. The MC model [20], [21] provides a unified and self-consistent description of the electrical and the noise performance of the device [22]-[24]. The validation of our simulation tool has been carried out by comparing simulations and measured results available in the literature. Additionally, this simulation tool has been used to analyze both the electrical and noise responses of Schottky mixers at THz frequencies and the physical effects that limit the performance of these circuits. Also the range of validity and the limitations of simpler simulation tools based on lumped equivalent circuits or drift-diffusion models have been evaluated using the Monte Carlo model as a reference.

The description of the simulation tool and the procedure for the evaluation of the mixer noise are described in Section II. The validation of the CAD tool is outlined in Section III, including a comparison of measured and simulated conversion losses and noise temperature for fundamental and subharmonically-pumped (SHP) mixers. An analysis of the performance of frequency mixers above 2.5 THz is presented in Section IV. In

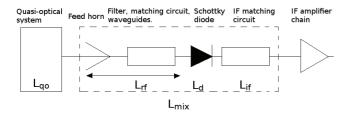


Fig. 1. Block diagram of a Schottky receiver.

Section V, the predictions of our simulation tool are compared with other CAD tools based on drift-diffusion and lumped equivalent circuit models. Some conclusions are drawn in Section VI.

II. SIMULATION FRAMEWORK

This section presents a brief description of the technique for modeling Schottky-based mixers using the MC model [25].

A. Figures of Merit of the Receiver

The block diagram of a Schottky diode receiver is shown in Fig. 1. The receiver consists of different elements which contribute to the total losses and noise temperature of the system. The total losses of the receiver are composed of $L_{\rm qo}$, losses in the quasi-optical parts of the systems (lens, diplexers, etc.), $L_{\rm rf}$, losses in the feed-horn, filters and mixer waveguides, L_d , the diode conversion losses, and $L_{\rm if}$, the resistive and mismatch losses in the IF matching circuit [26]–[28]:

$$L_{\rm rec} = L_{\rm qo} L_{\rm rf} L_d L_{\rm if}. \tag{1}$$

The equivalent input noise temperature of the receiver is evaluated using Friis' formula:

$$T_{\text{rec,DSB}} = (L_{\text{qo}} - 1)T_{\text{phys}} + L_{\text{qo}}T_{\text{mix,DSB}} + L_{\text{qo}}L_{\text{mix,DSB}}T_{\text{if}}$$

where DSB means double sideband¹, $T_{\rm phys}$ is the physical temperature and $T_{\rm if}$ is the noise temperature of the IF amplifier chain. This formula assumes that the different stages of the receiver are matched [29]. The mixer conversion loss $L_{\rm mix,DSB}$ and noise temperature $T_{\rm mix,DSB}$ are defined as:

$$L_{\text{mix,DSB}} = L_{\text{rf}} L_{d,\text{DSB}} L_{\text{if}}$$
 (3)

$$T_{\text{mix,DSB}} = (L_{\text{rf}} - 1)T_{\text{phys}} + L_{\text{rf}}T_{d,\text{DSB}} + L_{\text{rf}}L_{d,\text{DSB}}(L_{\text{if}} - 1)T_{\text{phys}}.$$
 (4)

Our simulator calculates the diode conversion losses $L_{d, \rm SSB}$ and noise temperature $T_{d, \rm SSB}$ and they are transformed into the corresponding DSB mixer or receiver ones using these equations and the data provided in the literature for $L_{\rm qo}$, $L_{\rm rf}$, $L_{\rm if}$ and $T_{\rm if}$.

Three different types of mixers have been considered in this work: Fundamental single-ended (F-SE) mixer with a single Schottky diode, fundamental balanced (F-B) mixers based on two diodes in a balanced configuration, and subharmonically pumped (SHP) mixers based on an antiparallel diode pair. The

 $^{\rm I}$ It has been assumed that the single sideband and double sideband conversion loss and noise temperature are related by [29]: $L_{d,\rm SSB}({\rm dB})=L_{d,\rm DSB}({\rm dB})+3~{\rm dB}$ and $T_{d,\rm SSB}(K)=2\cdot T_{d,\rm DSB}(K).$

simulation of the single-ended fundamental mixer is straightforward. To simulate the balance fundamental mixers, an equivalent single-diode mixer having the same conversion losses and noise temperature has been used [29]. For SHP mixers, the simulator analyses the real structure with two diodes in an antiparallel connection.

B. Description of the Monte Carlo Model

The Monte Carlo model provides a solution for the Boltzmann transport equation by simulating the trajectories of individual carriers as they move through a device under the influence of electric fields and random scattering forces [20], [21], [30]. Therefore, this technique provides an accurate description of physical phenomena in the device up to THz frequencies. An ensemble Monte Carlo self-consistently coupled with a one-dimensional Poisson solver has been used in this paper [24], [31]. The ohmic contact is modeled as a surface that injects carriers in thermal equilibrium with the lattice. In addition, any carrier reaching the contact leaves the device. On the other hand, the Schottky contact is simulated as a perfect absorbent surface. Scattering mechanisms included in the Monte Carlo simulation are ionized impurities, acoustic phonon, polar and non-polar optical phonon, and intervalley mechanisms. The band structure is modeled as a conduction band with three spherical non-parabolic valleys [20].

The MC method is recognized as the most rigorous technique for noise simulation since it allows the appropriate correlation functions to be calculated directly from a multi-particle history simulated during a sufficiently long-time interval [24]. Shot noise, thermal noise, hot electron noise and intervalley transfer noise [14], [22], [24], [31]–[33] as well as the effects due to the modulation of the noise sources by the voltage waveforms are inherently taken into account with this method. Besides, the coupling of fluctuations of the electron velocity and the electric field is also simulated with the MC model. The MC model has been successfully used to describe noise features of GaAs Schottky diodes under static and large-signal conditions [22]–[24], [31], [33].

In order to obtain reliable results for the conversion losses calculated with the MC model, the number of simulated particles has to be chosen large enough. Additionally, to calculate the noise temperature, the number of simulated particles and also the duration of the simulated history have to be sufficiently large to accurately evaluate the statistics of the current/voltage fluctuations of the device. Fig. 2 shows the conversion losses of the 585–690 GHz fundamental mixer in [34] simulated with the Monte Carlo model coupled to the harmonic balance technique (MCHB) as a function of the RF power ($P_{\rm RF}$) and the number of simulated particles. As the $P_{\rm RF}$ considered in the simulations decreases, the minimum number of simulated particles to assure accurate results with the MC model increases. In the simulations presented in this work, $P_{\rm RF}=-20$ dBm and more than 10000 particles in the MC model have been considered.

C. Coupling a Physical Device Model With a Circuit Simulator for Mixer Analysis

The HB method is the most common technique for the design of large-signal nonlinear microwave circuits [35]–[37]. The integration of numerical simulators for active devices into circuit

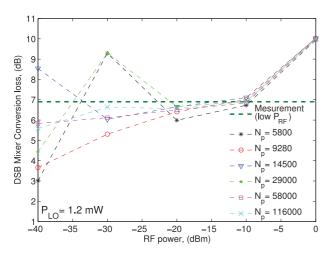


Fig. 2. Conversion losses of the 585 GHz–690 GHz fundamental mixer in [34] obtained with MCHB as a function of the number of simulated particles for different values of RF power. The LO power has been fixed to 1.2 mW, where the diode is operating in the vicinity of flat band, see Section III.

simulators avoids the need of an equivalent circuit model extraction. With this technique, the device-circuit interaction is taken into account and the mixers can be designed from both a device and circuit point-of-view [13].

The HB technique incorporates the benefits of the frequency domain analysis for the linear part of the circuit and the time domain analysis for the nonlinear part of the circuit. The time-domain current in the diode is evaluated using the MC model under the voltage waveform provided by the HB technique. This current is converted to the frequency domain, and then, different algorithms can be used to update the voltage applied to the terminals of the diode in terms of the circuit embedding impedances, the harmonic components of the current and the harmonic components of the voltage from the previous iterations [13], [37]. In mixers, the presence of multi-tone excitations makes necessary to take into account not only the different harmonics of the LO and the RF signals but also their intermodulation products $mf_{LO} + nf_{RF}$, with m and n integers. When f_{LO} and $f_{\rm RF}$ are commensurate, i.e., the quotient $f_{\rm LO}/f_{\rm RF}$ is rational, the multi-tone excitation can be defined as a periodic waveform by using the greatest common divisor of the LO and the RF frequencies, so the fast Fourier transform (FFT) can be employed. In the case where $f_{\rm LO}$ and $f_{\rm RF}$ are non-commensurate, the currents and voltages are not periodic, and thus the FFT is not applicable. There are several algorithms which can be used in this case [35]-[38]. Our multi-tone HB is based on the almost periodic Fourier transform (APTF) which is applicable to physics-based numerical models with memory [38].

A 5×3 box truncation scheme has been considered in simulations, where 5 and 3 are the highest harmonics of the LO and the RF frequencies, respectively (the total number of frequency components used with this scheme is 39, $f_{m,n} = mf_{\rm LO} + nf_{\rm RF}$ where $|m| \leq 5$, $|n| \leq 3$ and $f_{m,n} \geq 0$). Due to the practical impossibility of achieving optimum terminations at a large number of mixing frequencies, the impedances at mixing frequencies other than LO, RF, IF, and image frequencies have been set to zero in the simulations. Our simulator provides the possibility to conjugately match automatically the input impedances at the LO and RF frequencies at each operating point.

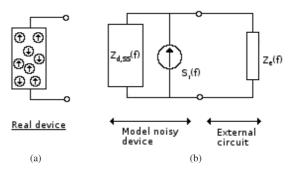


Fig. 3. (a) Noisy device and (b) equivalent circuit of a mixer at frequency f.

The presence of parasitic elements in the circuits, which may result in a degradation of the mixer performance, can be taken into account with our simulator. These elements—usually a parasitic capacitance and a parasitic inductance—are absorbed in the linear part of the circuit, see [13] for further details.

D. Evaluation of the Equivalent Input Noise Temperature of the Mixers With the MCHB Tool

Using Norton's theorem, a noisy diode can be represented by a noise current generator characterized by a current noise spectral density $S_I(f)$ obtained under short-circuit conditions in parallel with the small-signal impedance of the diode $Z_{d,\rm SS}$ or by a voltage noise generator characterized by a voltage noise spectral density $S_V(f)$ obtained under open-circuit conditions in series with $Z_{d,\rm SS}$ [39], see Fig. 3. The impedance $Z_{d,\rm SS}$ is a small-signal impedance which relates the fluctuations of the current and the voltage at the terminals the diode

$$Z_{d,SS}(f) = \left. \frac{V_{SS}(f)}{I_{SS}(f)} \right|_{V_{CO}} \tag{5}$$

where $V_{\rm LO}$ indicates that the diode is driven by the LO excitation, $V_{\rm SS}(f)$ is a small-signal sinusoidal voltage of frequency f superimposed to the LO signal at the terminals of the diode and $I_{\rm SS}(f)$ is the coefficient of the Fourier series of the small-signal current of frequency f (usually f is the intermediate frequency $f_{\rm IE}$).

In this section, a description of $S_I(f)$ and $Z_{d,SS}$ is presented as well as their evaluation with the MCHB tool in order to calculate the noise temperature of the mixers.

I) Calculation of $S_I(f)$: Firstly, the MCHB tools is used to calculate the voltage waveforms at the terminals of the diode and the conversion losses of the mixer for a given LO power. Then, the Schottky diode is simulated with the MC model under the voltage waveforms obtained with the MCHB tool, and the current noise spectral density $S_I(f)$ is evaluated. The current fluctuations $\delta I(t)^2$ obtained from the MC simulations can be used to calculate the correlation function $R_I(t,\tau) = \langle \delta I(t+\tau/2)\delta I(t-\tau/2)\rangle$, where $t\in [0,T_{\rm IF}]$ and $T_{\rm IF}$ is the period of the IF signal. The Fourier transform of $R_I(t,\tau)$ with respect to the correlation time τ determines the spectral density of the current fluctuations at time moment $t,S_I(t,f)$. The conventional power spectral density $S_I(f)$ used in this work is obtained by averaging $S_I(t,f)$ over the time t [24], [40].

 $^2I(t)=\langle I(t)\rangle+\delta I(t)$ where $\langle I(t)\rangle$ is the deterministic part of the current and the brakets $\langle\ldots\rangle$ mean averaging over an ensemble of different realizations of I(t) histories.

Data published in the literature for Schottky mixers																			
Mixer, (GHz)	f_{RF} ,	f_{LO} ,	P_{LO} ,			L_e ,		ϕ_b ,	R_s ,	$C_{j}(0),$	Z_{RF}	Z_{LO}	Z_{IF}	L_{qo}	L_{rf}	L_{if}	L_{mix} ,	T_{mix} ,	T_{if}
Wilker, (GHz)	(GHz)	(GHz)	(mW)	(V)	(cm^{-3})	(nm)	(μm^2)	(V)	(Ω)	(fF)	(Ω)	(Ω)	(Ω)	(dB)	(dB)	(dB)	(dB, dsb)	(K, dsb)	(K)
86-106 F-SE [27], [46]	93.4	92	1.5-2	0.65	$2x10^{17}$	100	4.91	0.85	7	6	80-j1	64+j51	110+j8 ^b		1.2		5.5	770	129
300-360 SHP [28], [47]	330	164.25	1.5-5.5	0	$2x10^{17}$	100	0.8	0.85	11-15	1.3	83+j53	147+j207	100		0.7	1	6	700	
585-690 F-SE [34], [42]	585	583.2	1.16		$2x10^{17}$		1.13		14	2	45+j30	45+j30	150	0.7	1.6	0.7	6.9	1490	100
835-900 F-B [48], [49]	865.8		1	~ 0.65	$5x10^{17}$		0.4	0.73	30	1	90+j200	17+j50	200		0.7	1.2	9.25	2660	
1200 SHP [50], [51]	~ 1200	~ 600	1.5-2.5	0.5													10.5h	2828 ^h	
2500 F-SE [52]	2514	2522	6	0.3-0.6	$1x10^{18}$	100	0.35		15-20					2		0.4	14.9	5665	150
4750 F-SE [53] ^a	4744	4750	1		$1x10^{18}$	30	0.05		20-40	0.25								70000	30
Data for Schottky mixers in our simulations																			
Mixer ^a (GHz)	f_{RF} ,	f_{LO} ,	P_{LO} ,			L_e ,		ϕ_b ,	R_s ,	$C_{j}(0),$	Z_{RF}	Z_{LO}	Z_{IF}	L_{qo}	L_{rf}	L_{if}	L_{mix} ,	T_{mix} ,	T_{if}
Wilker, (GHZ)	(GHz)	(GHz)	(mW)	(V)	(cm^{-3})	(nm)	(μm^2)	(V)	(Ω)	(fF)	(Ω)	(Ω)	(Ω)	(dB)	(dB)	(dB)	(dB, dsb)	(K, dsb)	(K)
86-106 F-SE [27], [46] ^g	100	90	1.5	0.65	$2x10^{17}$	100	4.91	0.85	7.01	7.3	80-j1	64+j51	110+j8		1.2		3.7	360	129
300-360 SHP [28], [47] ^g	360	168	1.5-5.5	0	$2x10^{17}$	80c	0.8	0.95^{d}	18.1°	1.15	83+j53	147+j207	100		0.7	1	5.7	700	
585-690 F-SE [34], [42] ^g	585	580	1.16	0.6	$2x10^{17}$	80	1.13	0.85	15	1.8	45+j30	45+j30	150	0.7	1.6	0.7	6.8	1710	100
835-900 F-B [48], [49]	900	870	1	0.65	$5x10^{17}$	100	0.4	0.75	30.3	1	90+j200	17+j50	200		0.7	1.2	9.9	2000	
1200 SHP [50], [51] ^g	1230	600	1.5-5.5	0.5	$5x10^{17}$	100	0.5	0.8	20	1.21	27+j14	38+j33	50		0.7	1.2	11.5	3590	П
2500 F-SE [52]	2500	2475	6	0.6	$1x10^{18}$	100	0.35	0.99	20.27	1.07	70+j113	86+j36	250	2		0.4	9-13	~5350	150
4750 F-SE [53] ^a	4750	4725	1	0.6	$1x10^{18}$	30	0.07e	0.99	40	0.25	130+i220	130+i220	250	2		0.4	10-33	4600-2x10 ⁵	30

TABLE I
PARAMETERS OF SCHOTTKY DIODE MIXERS PUBLISHED IN THE LITERATURE AND DATA USED IN OUR SIMULATIONS

- a Conversion losses and noise temperature are referred to mixers as defined by eqs. (3) and (4), respectively, except for the 4.75 THz mixer that are referred to the receiver
- b Measured circuit impedances at different intermodulation products are provided in [27], [46]: $Z[3f_{LO}-f_{RF}]=Z[f_{LO}+f_{RF}]=Z[2f_{LO}]=$ (6+28j) Ω ; $Z[2f_{LO}-f_{RF}]=Z[f_{RF}]=$ (80-1j) Ω . These impedances have been considered in our simulations.
- ^c Physics-based models with the parameters given in [28], [47] for the diodes in the 300-360 GHz SHP mixer (doping, length, anode area, barrier height) lead to a dc series resistance around 22 Ω which are larger than the values provided in the literature for the LEC model of the diode \sim 11-15 Ω . The simulated epilayer length has been reduced from 100 nm given in [47] to 80 nm to obtain $R_{s,dc}$ closer to the values provided in the literature.
- $^{\rm d}$ ϕ_b has been slightly shifted with respect to the value provided in [47] to get a better agreement between measured and simulated conversion losses.
- e The anode area has been selected to reproduce $C_j(0)$ given in literature for this diode.
- f Rs given in the literature is usually determined by a least-squares fit of the measured diode I-V curve to the standard exponential diode equation.
- 8 Parasitic capacitances C_p have been simulated when C_p is provided in the literature: C_p = 8.5 fF for the 86-106 GHz mixer, C_p = 5 fF for the 300-360 GHz SHP mixer, C_p = 5 fF for the 585-690 GHz mixer and C_p = 5 fF for the 1200 GHz SHP mixer.
- h Measured results for the design B in [51]. Measurements of the design A [51] are $L_{mix,DSB}$ = 12.5 dB and $T_{mix,DSB}$ = 4000 K

As an example, Fig. 4 shows the current noise spectra $S_I(f)$ for the 585–690 GHz fundamental mixer [34], see Table I, which lists the parameters of all the mixers analyzed in this work. Each noise spectrum in Fig. 4(a) can be divided into a low frequency region and a medium-high frequency region. The medium-high frequency region presents two peaks at frequencies around 3 THz and 10 THz, see Fig. 4(a). These peaks are due to the evolution of the carrier density fluctuations originated in the transitions between the neutral and the depleted regions of the epilayer (first peak) and between the substrate and the epilayer (second peak), commonly known as returning carrier and hybrid plasma peaks, respectively [23], [24], [31], [41].

In Fig. 4(b), the low frequency region of the noise spectra in Fig. 4(a) are compared with the shot and thermal noise contributions given by the following equation [41], [43]:

$$S_I(f \sim 0) = \frac{2qI_jR_j^2}{(R_s + R_j)^2} + \frac{4K_BTR_s}{(R_s + R_j)^2}$$
(6)

where R_s is the series resistance of the substrate and the non-depleted region of the epitaxial layer, R_j represents the junction resistance and I_j is the conduction current through the device. Although (6) is only valid under dc conditions [41], [43], it has been evaluated under the voltage waveforms obtained from MCHB using a lumped equivalent circuit (LEC) model that assumes $R_s(t)$, $R_j(t)$ and $I_j(t)$ in (6). As a result, $S_I(f \sim 0)$ in (6) becomes time dependent, i.e., $S_I(f \sim 0,t)$. The red solid curve in Fig. 4(b) is the time average of $S_I(f \sim 0,t)$ in an IF period for each LO power. A good agreement is observed between MC and the time average of this analytical model.

The LEC models used in this work are based on the LEC of the Schottky junction in series with a series resistance. The non-

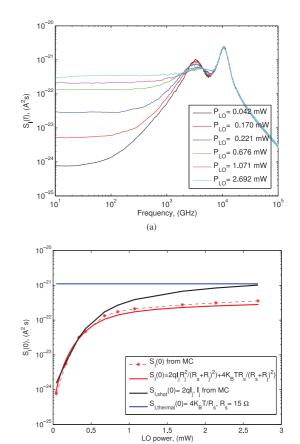


Fig. 4. (a) Noise spectra of the current fluctuations at the terminals of the diode in the 585–690 GHz fundamental mixer [34], [42], see Table I, under the voltage waveforms obtained with MCHB for $f_{\rm RF}=585$ GHz and $f_{\rm LO}=580$ GHz. (b) Comparison of the low frequency current noise spectra obtained with MC model in (a) and the shot and thermal noise contribution evaluated with LEC_{R₂(t)}. The junction resistance is time varying in the LEC model $R_i(t)$.

TABLE II
STEPS TO EVALUATE THE EQUIVALENT INPUT NOISE TEMPERATURE OF SCHOTTKY MIXERS USING THE MCHB TOOL AND THE CONVERSION MATRIX FORMALISM

$T_{d,SSB}$ at the IF frequency in Schottky mixers							
MCHB	Conversion matrix formalism with LEC models [6], [29], [36]						
 Calculate the voltage waveform at the terminals of the diodes and the conversion loss of the diode L_{d,SSB} for a given LO power with the multi-tone MCHB tool. Simulate the current noise spectral density S_I(f) of the diode with the MC model under the voltage waveform obtained in step 1). Calculate the small-signal impedance of the diode Z_{d,SS}(f), eq. (5), at the IF frequency using the MC model of the diode under the LO voltage waveform obtained in step 1). Evaluate the equivalent input noise temperature of the diode T_{d,SSB} at f_{IF} with eq. (8), using the conversion loss obtained in step 1), S_I(f_{IF}) from step 2) and Z_{d,SS}(f_{IF}) from step 3). 	 Calculate the voltage waveform at the terminals of the diodes under the large-signal LO excitation only, using the harmonic balance technique and simple LEC diode models. The nonlinear elements of the device modulated by the LO waveforms obtained from step 1) are converted into linear, time varying elements. These linear elements relate the small-signal time varying voltages and currents at the terminals of the diode. The analysis of the small-signal voltages and currents in the frequency domain leads to the conversion matrix. The noise correlation matrix for the different noise sources are calculated using analytica models and the LO waveforms. The conversion and correlation matrices obtained in steps 3) are used to evaluate Ld,SSB, the impedance of the diode at any mixing frequency and Td,SSB, see appendix A. 						

linear capacitance is modeled with a fully depleted approximation and the conduction current through the Schottky contact is approached by thermionic emission equation [44]. Under time varying conditions, both the nonlinear capacitance, $C_j(t)$, and the nonlinear resistance, $R_j(t)$, are assumed time varying in the LEC models. Diode models with the dc series resistance of the diode $R_{s,\mathrm{dc}}$ (the series resistance measured when the epilayer is undepleted) and with the time varying series resistance $R_s(t)$ due to the time variation of the width of the depletion region [5], [45] have been used. These model are denoted by $\mathrm{LEC}_{R_{s,\mathrm{dc}}}$ and $\mathrm{LEC}_{R_s(t)}$ respectively. Also, a LEC model which takes into account carrier inertia and displacement current in undepleted regions of the device by means of an inductance and a capacitance [7], respectively, has been considered ($\mathrm{LEC}_{R_s,\mathrm{LC}(t)}$ model).

2) Calculation of $Z_{d,SS}$: The impedance $Z_{d,SS}$ depends on the LO signal and the bias point. It also depends on the embedding impedances of the mixer circuit at frequencies different from the frequency at which $Z_{d,SS}$ is evaluated. $Z_{d,SS}$ can be calculated directly according to its definition in (5): The diode is excited with the LO voltage waveforms at the terminals of the diode obtained from the MCHB simulations and a small-signal sinusoidal voltage at the IF frequency- $V_{SS}(f_{IF})$ -superimposed to the LO voltage waveform. The contribution to the current response of the diode is evaluated and the small-signal impedance at the IF frequency $Z_{d,SS}(f_{IF})$ is calculated using (5).

Fig. 5 presents a comparison of $Z_{d,SS}(f_{IF})$ obtained with MCHB and the output impedance of the pumped diode $Z_{out}(f_{IF})$ defined in the conversion matrix (CM) formalism [6], [29], see Appendix A, for the diode in the 585–690 GHz fundamental mixer. A good agreement is observed between $Z_{d,SS}(f_{IF})$ and $Z_{out}(f_{IF})$ from the CM formalism using $LEC_{R_s,dc}$ and $LEC_{R_s(t)}$ models. The real part of these impedances decreases as the LO power increases because the nonlinear resistance of the Schottky junction decreases as the diode approaches flat band conditions. On the other hand, the performance of the imaginary part is determined by the nonlinear capacitance of the diode (increasing the input power, the swept of the nonlinear capacitance increases until it reaches flat-band conditions).

3) Evaluation of the Equivalent Input Noise Temperature: Once $S_I(f_{\rm IF})$ and $Z_{d,\rm SS}(f_{\rm IF})$ have been calculated, the noise power delivered to the output impedance of the mixer circuit at

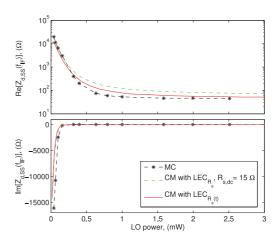


Fig. 5. Real and imaginary parts of the impedances $Z_{d,\rm SS}(f_{\rm IF})$ calculated with MCHB and $Z_{\rm out}(f_{\rm IF})$ defined in the conversion matrix formalism, see Appendix A, for the diode in the 585–690 GHz fundamental mixer at IF frequency 5 GHz.

 $f_{\rm IF}, Z_e(f_{\rm IF})$, see Fig. 3, is given by the following expression, obtained from the analysis of the circuit in Fig. 3(b):

$$P_{\text{del}}(f_{\text{IF}}) = \frac{S_I(f_{\text{IF}})\Delta f \cdot \text{Re}[Z_e(f_{\text{IF}})] \cdot |Z_{d,\text{SS}}(f_{\text{IF}})|^2}{|Z_{d,\text{SS}}(f_{\text{IF}}) + Z_e(f_{\text{IF}})|^2}$$
(7)

where Δf is the bandwidth of interest. The single sideband equivalent input noise temperature of the diode is defined as [6], [29]

$$T_{d,\text{SSB}} = \frac{P_{\text{del}} L_{d,\text{SSB}}}{k_B \Delta f} \tag{8}$$

where $L_{d, \rm SSB}$ is the single sideband conversion loss of the diode between the RF and the IF signals. Once the single sideband noise temperature of the diode is calculated, the double sideband noise temperature of the mixer and the receiver can be evaluated using (4) and (2), respectively. Table II shows a summary of the procedure to calculate the equivalent input noise temperature of Schottky mixers with the MCHB tool and the CM formalism.

III. VALIDATION OF THE MIXER SIMULATION TOOL

The validation of the MCHB tool has been carried out by comparing simulation results with measurements published in

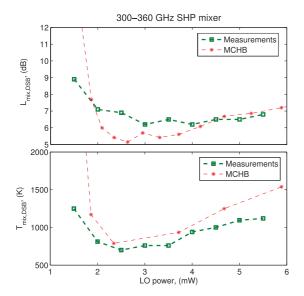


Fig. 6. DSB conversion losses equation (3) and noise temperature equation (4) of the 300–360 GHz SHP mixer [47] as a function of the LO power.

the literature for Schottky mixers, see Table I. Mixers are usually measured at the available LO power, and hence, most of the publications only present measurements for a fixed LO power. The circuit impedances at the LO, RF and IF frequencies in the literature have been used in the simulations. The IF frequencies considered in our simulations have been chosen higher than those used in measurements to decrease the computational cost of the MCHB, see Table I. However, it has been tested that these differences have a low impact on the simulation results (see the results in Section IV-A for the 2500 GHz mixer at IF frequencies 5 and 25 GHz).

Fig. 6 shows a good agreement between measured and simulated results of $L_{\rm mix,DSB}$ and $T_{\rm mix,DSB}$ for the 300–360 GHz SHP mixer [47], see Table I.

A comparison between measured and simulated results for $L_{\rm rec,DSB}$ and $T_{\rm rec,DSB}$ of the 585–690 GHz fundamental mixer in [34] is shown in Fig. 7, see Table I. Since the bias voltage $V_{\rm bias}$ of this mixer is not provided in the literature³, $V_{\rm bias} = 0.6$ V and 0.75 V have been simulated with the MCHB tool. By increasing the bias point, the LO power to achieve the minimum conversion losses is lower. Besides, the minimum conversion losses are higher for higher bias due to the lower modulation of the nonlinear resistance of the Schottky diode. The noise temperature is lower when $V_{\rm bias}$ is 0.6 V since the conversion losses with this $V_{\rm bias}$ are lower.

A good agreement is observed between measurements and simulations in Fig. 7. Additional measured results for a 585 GHz fundamental mixer similar to that in [34] have been presented in [54]⁴, with a minimum receiver noise temperature of 1700 K. This noise temperature is in good agreement with the minimum $T_{\rm rec,DSB}$ obtained with MCHB for $V_{\rm bias}=0.6$ V, see Fig. 7.

The 1.2 THz SHP mixer described in [51] has been simulated with our MCHB tool, see Fig. 8. Measured data for the designs A and B presented in [51] are included in this figure. According

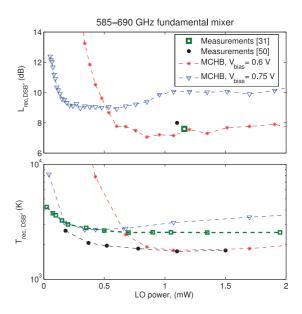


Fig. 7. DSB conversion losses equation (1) and noise temperature equation (2) of the 585–690 GHz fundamental receiver [34] as a function of the LO power.

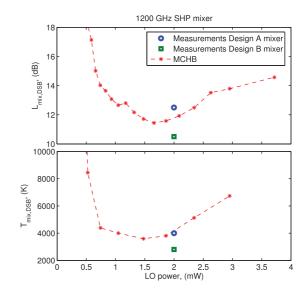


Fig. 8. DSB conversion losses equation (3) and noise temperature equation (4) of the 1200 GHz SHP mixer [51] as a function of the LO power.

to [51], mixer design A was optimized to provide an operating bandwidth from 1080 to 1280 GHz (17%), and mixer design B was optimized to provide the highest possible sensitivity in the 1120–1280 GHz band. The parameters used for the simulation of this mixer are shown in Table I. Due to the lack of information in [51], the following strategy has been used in the simulation of this mixer.

- The parameters of the diodes in [55] for a 874 GHz SHP mixer have been adopted for the diodes in the 1.2 THz SHP mixer. This was indicated in [50] for the design of a 1.2 THz mixer.
- The circuit impedances at the RF, LO and IF frequencies have been optimized with the MCHB tool at LO power 2 mW. A parasitic capacitance of 5 fF has been considered.
- Losses $L_{\rm qo}=0$ dB, $L_{\rm rf}=0.7$ dB, and $L_{\rm if}=1.2$ dB given in [48], [49] for the 835–900 GHz fundamental balanced mixer have been assumed.

³According to [34], bias voltages used in measurements were optimized at each LO power to minimize the noise temperature.

 $^{^4}The$ epilayer doping concentration of the diode in [54] is 4×10^{17} cm $^{-3}$, while for the diode in [34] is 2×10^{17} cm $^{-3}$.

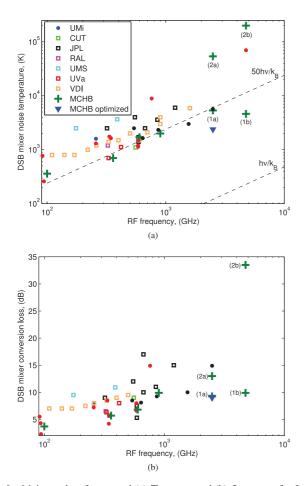


Fig. 9. Main results of measured (a) $T_{\rm mix,DSB}$ and (b) $L_{\rm mix,DSB}$ for fundamental (solid circles •) and SHP (squares \square) planar Schottky mixers available in the literature since 1991. Measurements and MCHB simulation results for the mixers in Table I are included in this figure. The 4.75 THz mixer is based on a whisker diode and the measurements are for the receiver instead. The data in the legend indicate the laboratory which built the diodes: CUT: Chalmers University of Technology. JPL: Jet Propulsion Laboratory. RAL: Rutherford Appelton Laboratory. UMi: University of Michigan. UMS: United Monolithic Semiconductor. UVa: University of Virginia. VDI: Virginia Diodes, Inc.

Simulation results in Fig. 8 show a good agreement with the measurements provided in [51].

An additional validation of the MCHB tool is shown in Fig. 9, which presents the main results in the literature for $L_{\text{mix},DSB}$ and $T_{\text{mix,DSB}}$ of planar Schottky mixers together with MCHB simulation results for the mixers in Table I. At RF frequencies below 2.5 THz, MCHB simulation results show a good agreement with measurements. For the 2.5 THz mixer, the minimum values of $L_{
m mix,DSB}$ and $T_{
m mix,DSB}$ [PLO ~ 5 mW, denoted by (1a)] as well as those obtained at the available LO power $[P_{LO} = 6 \text{ mW}, \text{ denoted by (2a)}]$ are indicated, see Fig. 10. Also, simulated results from the optimization of this mixer are included. Simulation results for the 4.75 THz fundamental mixer in [53] are also included in Fig. 9. Since $L_{\rm op}$, $L_{\rm rf}$ and $L_{\rm if}$ are not published for this mixer, those given for the 2.5 THz mixer have been considered in the simulations. As for the 2.5 THz mixer, minimum values of simulated $L_{
m rec,DSB}$ and $T_{
m rec,DSB}$ [denoted by (1b)] and the values obtained at the available input power $[P_{LO} = 1 \text{ mW}, \text{ denoted by (2b)}]$ are shown, see Fig. 14. The performance of these mixers and mixers above 2.5 THz are analyzed in Section IV.

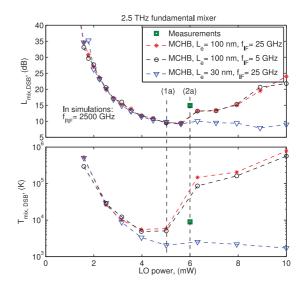


Fig. 10. DSB conversion loss and noise temperature of the 2.5 THz fundamental mixer—(3) and (4)—described in Table I with $L_e=100$ and 30 nm, obtained with MCHB. IF frequencies 5 and 25 GHz have been simulated to justify the use of high IF frequencies in simulations, as discussed at the beginning of Section III.

IV. ANALYSIS OF SCHOTTKY MIXERS ABOVE 2 THZ

The analysis and design of Schottky mixers require reliable simulation tools to account for the physical effects which determine the performance of the devices. For high RF frequencies, the electrical and noise responses of the Schottky diodes are limited by physical effects like velocity saturation, plasma resonance and nonlocal effects both in time and space. An analysis of the impact of these phenomena in the performance of Schottky mixers is carried out in this section using the MCHB tool

A. Results for a 2.5 THz Fundamental Mixer

Fig. 10 shows the DSB conversion losses and the equivalent input noise temperature of the 2.5 THz fundamental mixer in [52] as a function of the LO power, see Table I. Two values of the epilayer length L_e have been simulated: 100 nm according to [52], and 30 nm, in order to optimize the performance of the mixer. Lines (1a) and (2a) indicate the values included in Fig. 9.

MCHB simulation results show an abrupt increase of the conversion losses at $P_{\rm LO}{\sim}6$ mW (flat band conditions are achieved at $P_{\rm LO}{\sim}4$ mW) when $L_e=100$ nm. This performance is due to velocity saturation effects originated by the increase of the occupation of the lower mobility upper valleys (L,X) in the undepleted region of the epilayer of the diode. MCHB shows occupations of the L valley around 5% at $P_{\rm LO}=2.5$ mW, reaching $\sim\!20\%$ at 5 mW; at higher LO power, the population of the L valley increases quickly, with maximum occupation around 60% at $P_{\rm LO}{\sim}6.3$ mW. Also, the transfer to the X valley increases abruptly when the LO power increases from 5 to 6.3 mW, rising from occupations lower than 5%–20%, see Fig. 11.

The noise temperature of the mixer is also degraded when the LO power is higher than 4 mW, see Fig. 10. As the electric field in the undepleted epilayer increases when the LO power increases, the energy of the electrons is increased above the equilibrium thermal energy. This effect increases the diode noise

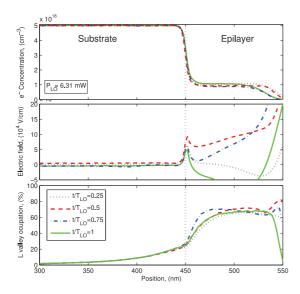


Fig. 11. Profiles of the electron concentration, the electric field, and the occupation of the L valley (percentage of electrons in the L valley) for the 2.5 THz mixer with $L_{\epsilon}=100$ nm, obtained with MC at different times in a LO period $(T_{\rm LO})$.

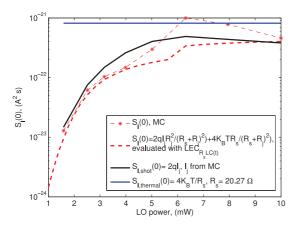


Fig. 12. Comparison of the low frequency region of the current noise spectra obtained with the MC model for the diode in the 2.5 THz mixer under the voltage waveforms from MCHB for different LO powers. The shot and thermal noise contribution of (6) evaluated with a $\text{LEC}_{R_sLC(t)}$ model using the voltage waveforms obtained with MCHB is also included. The dc component of the current I_0 in the $2qI_0$ law has been obtained with the MC model.

temperature, giving rise to hot electron noise [14], [15]. When the electric field is high enough for intervalley transfer to take place, the stochastic transitions between the lowest and upper valleys of the semiconductor generate a new contribution to the noise spectrum usually known as intervalley scattering noise [14], [22]. For the mixer with $L_e = 100$ nm in Fig. 10, an abrupt increase of the noise temperature is observed at P_{LO} around 6 mW due to the quick increase of the intervalley transfer at these LO powers. The increase of noise due to hot electrons and intervalley transfers at P_{LO} higher than 4 mW is observed in Fig. 12, where the low frequency region of the current noise spectra obtained with the MC model for this mixer is compared with (6) assumed time varying for the combined contribution of shot and thermal noise. In this figure, (6) is evaluated with a $LEC_{R_sLC(t)}$ model under the voltage waveforms obtained from the MCHB simulations.

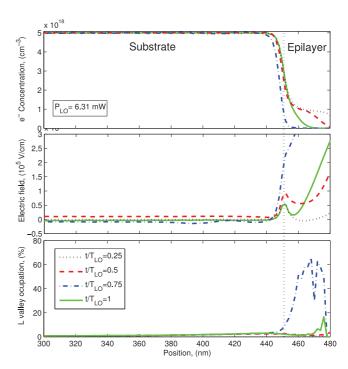


Fig. 13. Profiles of the electron concentration, the electric field, and the occupation of the L valley for the 2.5 THz mixer with $L_e=30$ nm, obtained with MC at different times in a LO period $(T_{\rm LO})$.

In order to optimize the performance of this mixer, the epilayer length L_e is set to 30 nm (the epilayer length of the diode in the 4.75 THz mixer, see Table I). The abrupt increase of the conversion losses and the noise temperature observed in Fig. 10 for $L_e = 100$ nm disappears. In the optimized diode, the epilayer is totally depleted during a high temporal fraction of a LO period, see Fig. 13, what mitigates velocity saturation effects. Besides, nonlocal transport effects [11], [30] are important in the performance of this diode. The electrons in the substrate (low field region) enter into the epilayer (high field region), where they move with a velocity higher than expected from the equilibrium velocity field curve. In addition, the mean free path of the electrons in the epilayer is of the order of the epilayer length $(L_e = 30 \text{ nm})$, and ballistic transport is important. Due to these effects, most of the electrons remain in the lower valley (according to MCHB, the occupation of the upper valleys remains lower than 5% when $L_e = 30$ nm for the simulated power swept), see Fig. 13. Therefore, the conversion losses and the noise temperature remain nearly constant at P_{LO} higher than 4 mW for $L_e = 30$ nm, in contrast to the abrupt increase of these parameters observed for the diode with $L_e = 100$ nm at P_{LO} around 6 mW, see Fig. 10.

B. Results for a 4.75 THz Fundamental Mixer

The 4.75 THz mixer in [53] is based on a Schottky diode with $L_e=30$ nm, see Table I. Fig. 14 shows the conversion losses and the noise temperature obtained from the MCHB simulations of this mixer (since $L_{\rm op}$, $L_{\rm rf}$ and $L_{\rm if}$ are not provided for the 4.75 THz mixer, those given for the 2.5 THz mixer in [52] have been used to evaluate $L_{\rm rec}$ and $T_{\rm rec}$). Lines (1b) and (2b) indicate the values included in Fig. 9. Intervalley transfer effects are highly mitigated due the short length of the epilayer of the diode, as was described for the for the 2.5 THz mixer

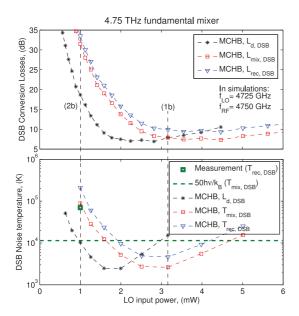


Fig. 14. DSB Conversion losses and noise temperature of the 4.75 THz fundamental mixer described in Table I, obtained with MCHB at $f_{\rm IF}=25$ GHz. Results for the diode (black lines), the mixer (red lines) and the receiver (blue lines) are presented. $L_{\rm op}$, $L_{\rm rf}$ and $L_{\rm if}$ of the 2.5 THz mixer have been used to evaluate the mixer and the receiver characteristics.

with $L_e=30$ nm. The simulated $T_{\rm rec,DSB}$ at the available LO power ~ 1 mW is of the order of the measured results. Simulations indicate that higher LO power is required to get lower noise temperature. Accurate information about the real losses $L_{\rm op}, L_{\rm rf}$ and $L_{\rm if}$ of this mixer will provide a better interpretation of the measured receiver noise temperature. On the other hand, the 4.75 THz mixer in [53] is an old design based on whisker technology.

C. Schottky Mixers up to 10 THz

According to the results in previous subsections, a short epilayer length is necessary to mitigate intervalley transfer effects. Hence, in this section, an analysis of Schottky mixers up to signal frequency 10 THz is carried out, using as a reference the diode of the 4.75 THz fundamental mixer [53], Table I, characterized by an epilayer of length 30 nm, doping concentration $1\times10^{18}~{\rm cm}^{-3}$, anode area $0.07~{\mu}{\rm m}^2~(C_j(0)=0.25~{\rm fF})$ and series resistance $40~\Omega$. In the simulation of these mixers, the circuit impedances at the RF and LO frequencies have been conjugately matched for each LO power considered. The IF impedances $Z_{\rm IF}$ have been set to 250 Ω for all the designs. $L_{\rm qo}=1$ dB, $L_{\rm rf}=2$ dB, and $L_{\rm if}=1$ dB have been assumed. These are reasonable losses for the THz frequencies considered in this subsection.

Fig. 15 shows the mixer conversion losses of the 2.5 THz, 4.75 THz and 10 THz fundamental mixers based on the reference diode in this subsection, obtained with MCHB. When the signal frequency is increased, both the minimum conversion losses and the LO power to achieve these minimum conversion losses increase. This degradation of the mixer performance is due to the shunting effect of the junction capacitance (C_j) over the junction resistance (R_j) of the diode [56]. At high frequencies, smaller anode areas are beneficial since they contribute to

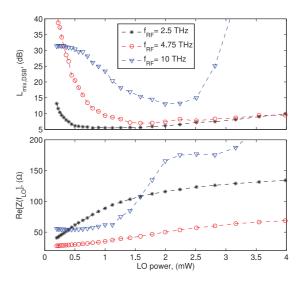


Fig. 15. Comparison of the mixer conversion losses and the real part of the diode impedance at the LO frequency as a function of the LO power for the 2.5, 4.75, and the 10 THz fundamental mixers based on the reference diode ($f_{\rm IF}=25~{\rm GHz}$). The anode area of the diode is 0.07 $\mu{\rm m}^2$. Results obtained with MCHB.

achieve the minimum conversion losses at lower LO powers. On the other hand, smaller anode areas at these frequencies are beneficial to obtain easy to match mixers [56].

Fig. 15 shows the real part of the diode impedance Z_d at the LO frequency as a function of the LO power for the mixers analyzed in this subsection. When the signal frequency is increased from 2.5 to 4.75 THz, the real part of the diode impedance decreases due to the shunting of the nonlinear capacitance. When the signal frequency is increased to 10 THz, $Re[Z_d]$ at low LO power increases due to plasma effects in the undepleted epilayer (plasma frequency of the epilayer is around 9.6 THz, see [7]). At LO power higher than 1 mW, the occupation of the upper valleys of the 10 THz mixer increases quickly, resulting in the abrupt increase of $\operatorname{Re}[Z_d]$ observed in Fig. 15. The MC simulations of this mixer show that, at $P_{LO} = 1$ mW, the maximum occupations of the L and X valleys in the undepleted regions of the diode are around 27% and 1.5%, respectively, and at $P_{\mathrm{LO}}=1.4$ mW they are around 46% and 5% (for comparison, at $P_{LO} = 3$ mW, the occupations of the L and X valleys in the 2.5 THz mixer are lower than 12% and 3%, respectively, and for the 4.75 THz mixer they are lower than 25% and 5%.).

The equivalent input noise temperature of the mixer $T_{\mathrm{mix,DSB}}$ and the equivalent noise temperature of the diode $T_{\mathrm{noise},d}$ ⁵ in the 2.5 THz, 4.75 THz and the 10 THz fundamental mixers based on the reference diode of this subsection are shown in Fig. 16. For the 2.5 and 4.75 THz mixers and up to LO powers around 1.3 mW, $T_{\mathrm{noise},d}$ increases due to shot and thermal noise contributions. At higher LO powers, hot electron noise and intervalley transfer noise lead to a further increase of $T_{\mathrm{noise},d}$. These noise components are more important in the 4.75 THz mixer because the electron energy and the occupation of the L valley are higher. For the 10 THz mixer, hot electron noise and intervalley transfer noise are important at $P_{\mathrm{LO}} = 1$ mW, leading to

 $^{^5}T_{\mathrm{noise},d}$ is not referred to the input, i.e., it represents the noise power of the diode delivered to the IF load, $T_{\mathrm{noise},d} = P_{\mathrm{del}}/k_B \Delta f$, see (8).

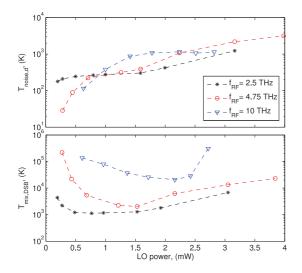


Fig. 16. Equivalent noise temperature $T_{\mathrm{noise},d}$ of the diode and double side band equivalent input noise temperature $T_{\mathrm{mix,DSB}}$ of the reference 2.5 THz, 4.75 THz and the 10 THz fundamental mixers, obtained with MCHB.

TABLE III OPTIMUM VALUES OF N_e AND L_e OBTAINED WITH THE MCHB TOOL FOR MIXERS ABOVE 1 THZ. THE MINIMUM $L_{ m mix}$ AND $T_{ m mix}$ AS WELL AS THE VALUES AT THE AVAILABLE LO POWER ARE SHOWN. THE RESULTS USING THE DESIGNS IN TABLE I ARE INCLUDED FOR COMPARISON

Optimum designs										
Mixer	N_e	L_e	$L_{mix}^{\mathbf{a}}$	$T_{mix}^{\mathbf{a}}$						
IVIIACI	(cm^{-3})	(nm)	(dB, DSB)	(K, DSB)						
1200 GHz subharmonic	$5x10^{17}$	50	8.7-10.35	1510-2890						
2500 GHz fundamental	$1x10^{18}$	30	4.1-5.6	610-810						
4750 fundamental	$2x10^{18}$	30	4.2-7.8	1190-1720						
Designs from Table I										
Mixer	N_e	L_e	$L_{mix}^{\mathbf{a}}$	$T_{mix}^{\mathbf{a}}$						
WHACI	(cm^{-3})	(nm)	(dB, DSB)	(K, DSB)						
1200 GHz subharmonic	$5x10^{17}$	100	11.5	3590						
2500 GHz fundamental	$1x10^{18}$	100	9.25-13	5350-54000						
4750 fundamental	$1x10^{18}$	30	7.9-28.0	2620-88830						

^a Minimum values of the conversion losses and noise temperatures and values at the available LO power are separated by a "-".

values $T_{\mathrm{noise},d}$ higher than for the other two mixers. This performance of $T_{\mathrm{noise},d}$ and the degradation of the conversion losses at high frequencies described in Fig. 15 lead to the increase of the minimum values of $T_{\mathrm{mix},\mathrm{DSB}}$ when the operation frequency increases, see Fig. 16.

An in-depth analysis of the impact of the epilayer length and the epilayer doping on the performance of the 1.2 THz SHP mixer, the 2.5 THz fundamental mixer and the 4.75 THz fundamental mixer described in Table I has been carried out using the MCHB tool. The optimum values of N_e and L_e for these mixers and the predicted conversion losses and noise temperatures are compiled in Table III. In the optimization of these mixers, the circuit impedances at the RF and the LO frequencies have been conjugately matched at each operating point. The output impedances at the IF frequencies have been fixed to the values provided in Table I. In addition, the bias voltage and the anode area shown in Table I have been used in the optimization. The results obtained using the mixer designs in Table I are included in Table III for comparison. The reduction of the conversion losses after optimization of both the device structure and the circuit (impedance matching) has direct impact on the noise temperature, as can be seen using (3) and (4).

V. Frequency Mixers Performance Evaluated With Different Models

Fig. 17 shows a comparison of the conversion losses and the noise temperature of some mixers described in Table I, obtained with different models coupled to the multi-tone HB tool. Also, measured results available in the literature have been included. The following models have been used in this analysis: A lumped equivalent circuit based on the constant series resistance presented in Table I (denoted by $LEC_{R_{s,dc}}HB$); a lumped equivalent circuit based on a time varying series resistance (LEC_{$R_s(t)$}HB); drift-diffusion models based on the steady-state velocity-field curve of GaAs (DDHB) and the constant low field mobility of GaAs (DD₀HB). The noise temperature of the mixers has been calculated with the MCHB tool as described in Subsection II.D and with LEC models using the conversion matrix (CM) formalism presented in [6] and [29], see Appendix A. The traditional formulation of the CM uses a $LEC_{R_{s,dc}}$ model and it takes into account shot and thermal noise contributions. The effects of the modulation of the shot noise source under the LO signal is taken into account by using analytical noise correlation matrices. Hot electron noise and the effects of its modulation by the LO have been also included in the CM as described in [56]. Additionally, when we use the $LEC_{R_s(t)}$ model in the CM, we have also taken into account the effects of the modulation of the thermal noise by the LO signal [57].

The models described in previous paragraph and used in Fig. 17 are commonly used in mixer design [5], [15], [34], [47], [49]. In [51], a lumped equivalent circuit model that takes into account carrier inertia and displacement current in the undepleted epilayer has been used to design a 1.2 THz SHP mixer. This model uses an average electron temperature to take into account hot electron noise, neglecting the correlation contributions of this noise component. On the other hand, a drift-diffusion diode model coupled to a time-domain circuit simulator has been used in [58] for the analysis of a 2.5 THz fundamental mixer. In [59], an *ad-hoc* improvement of the DD model to extend its validity under flat band conditions has been used to carry out an analysis of Schottky mixers.

Due to the accuracy of the MC model, the predictions of the MCHB tool have been considered as a reference to evaluate the accuracy and range of validity of other models. The most relevant results from Fig. 17 as regards the conversion losses are as follows.

- According to MCHB, velocity saturation does not affect the performance of the mixers up to 1 THz, due to the high doping and bias voltages used. As a consequence, a good agreement is observed between the predictions of MCHB and DD₀HB which assumes a constant low field mobility.
- The traditional DD model (DDHB) fails when the diodes are working in the vicinity of flat band conditions. Above flat band, high electric fields are generated close to the Schottky contact. MC simulations show that nonlocal transport is important in this region. Since DD is a local model which uses a field dependent mobility, it overestimates the series resistance of this high field region. Also, local modeling of the electron transport in the n⁺-n transition with the DD model contributes to overestimate the series resistance of the diode. As a consequence, DD

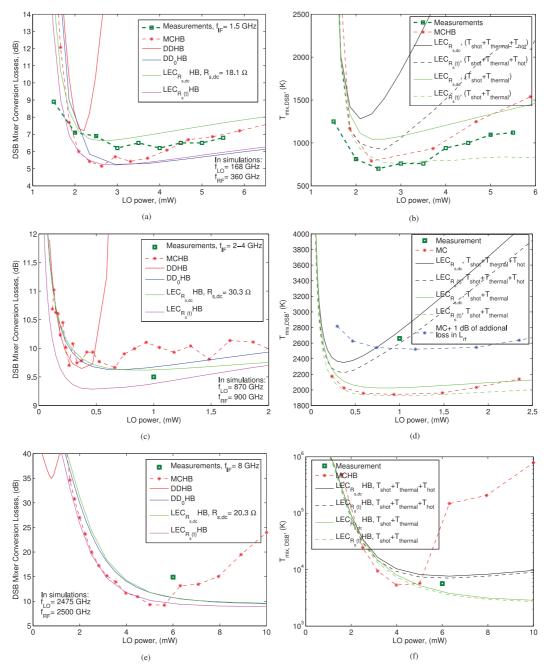


Fig. 17. DSB conversion losses (3) (left column) and equivalent input noise temperature (4) (right column) of the mixers described in Table I as a function of the LO power, simulated with LECHB, DDHB and MCHB tools. (a) 300–360 GHz subharmonic mixer, (b) 300–360 GHz subharmonic mixer, (c) 835–900 GHz fundamental balanced mixer, (d) 835–900 GHz fundamental mixer.

overestimates the conversion losses of the mixers. Since DD_0 assumes a constant low field mobility independently of the electric field, it does not overestimate the series resistance, leading to a good agreement with the MC model.

- The predictions of the $LEC_{R_s(t)}HB$ are in good agreement with the results from DD_0HB . On the other hand, since $LEC_{R_s}HB$ uses a constant R_s , it overestimates the series resistance of the diode and, hence, overestimates the conversion losses.
- Velocity saturation is important in the performance of the 2.5 THz mixer, see Section IV.A. DD₀ and LEC models underestimate the conversion losses of this mixer, since they assume a constant low field electron mobility.

The most important conclusions from Fig. 17 as regards the noise temperature are:

• For the mixers up to 1 THz, the comparison of the results from the CM approach using different LEC models and MCHB indicates that the noise temperature at these frequencies is essentially determined by shot and thermal noise contributions. The calculation of the noise temperature with the CM approach is highly affected by the accuracy of the LEC model considered: Using a LEC_{Rs} model, the noise temperature is overestimated since this model overestimates the series resistance of the diode. Noise temperature evaluated with a time varying series resistance shows a better agreement with the results obtained with MCHB.

- According to MCHB, hot electron noise contribution evaluated with the equations presented in [15], [60] is overestimated. The model in [15], [60] depends on the energy relaxation time τ_{ϵ} . τ_{ϵ} is a function of the doping concentration and the electron energy, but it is used as an empirical parameter in the hot electron noise model. The results from MCHB provide a reference to analyze the limitations of this model.
- Results from Monte Carlo simulations indicate that intervalley transfer generates an important noise contribution for the 2.5 THz mixer at $P_{\rm LO}$ higher than 4 mW, see Subsection IV.A.
- Some discrepancies are observed between measurements and simulation results for the 835–900 GHz fundamental balanced mixer, see Fig. 17(d). Since MC simulations indicate that there is not hot electron noise for this mixer, the observed discrepancies should be related to additional losses in other elements of the mixer. In fact, assuming additional losses of 1 dB in $L_{\rm qo}$, $L_{\rm rf}$ or $L_{\rm if}$, the observed discrepancies can be explained.

VI. CONCLUSION

A reliable simulation tool for the analysis and design of Schottky-based mixers at millimeter and submillimeter wavelengths has been developed by combining a Monte Carlo device model with a multi-tone harmonic balance technique.

We have obtained good agreement between published experimental results and calculations with MCHB for both conversion losses and noise temperatures of Schottky mixers up to 2.5 THz. In addition, a significant reduction of the intervalley scattering noise which appears at high frequencies has been predicted by the MCHB tool when the epilayer length is decreased.

The analysis of Schottky mixers using different diode models has shown that DD_0 and improved LEC models describe correctly the conversion losses when there is no velocity saturation (RF frequencies lower than 1 THz). On the other hand, the traditional DD model fails when the diodes are working close to flat band.

Up to frequencies around 1 THz, the noise temperature of mixers is usually well predicted by the ordinary shot and thermal noise theory. MC simulations have shown that common analytical models for hot electron noise integrated in the conversion matrix formalism overestimate this noise contribution. At frequencies higher than 1 THz, Monte Carlo simulations have shown an important increase of the noise temperature due to intervalley transfer.

APPENDIX CONVERSION MATRIX FORMALISM

This appendix presents an overview of the conversion matrix (CM) formalism for the analysis of Schottky mixers [6], [29], [36]. The CM or large-signal-small-signal approach assumes that the nonlinear device is pumped by a single large sinusoidal signal (LO) together with another signal with much smaller amplitude (RF). The following steps summarize the procedure to calculate the conversion losses and the noise temperature of mixers.

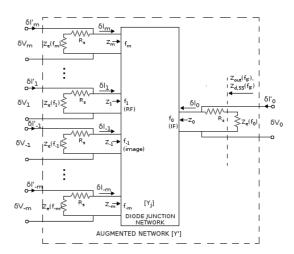


Fig. 18. Small signal representation of the mixer as a multifrequency linear multiport circuit. The voltage and current δV_m and $\delta I'_m$ at any port m are the small-signal components at frequency $f_{\rm IF}+mf_{\rm LO}$ of the augmented network; each port represents one sideband frequency. During normal mixer operation the equivalent signal current generator is connected at port 1 of the augmented network, the other ports being open-circuited. In the noise analysis, equivalent noise current sources $\delta I'_{S,m}, \delta I'_{T,m}$ and $\delta I'_{H,m}$ are connected to all ports. Reproduced from [6].

- Simulation of the nonlinear circuit under the large-signal LO excitation only, using the harmonic balance method together with a diode model. A lumped equivalent circuit model of the diode is commonly used in the CM formalism.
- The nonlinear elements of the diode modulated by the LO waveforms obtained from the first step are converted into linear, time varying elements, using the incremental conductance $g_j(t)$ and capacitance $c_j(t)$ of the Schottky junction.
- The small-signal voltages v(t) and currents i(t) at the terminals of the diode are analyzed in the frequency domain (the vectors of the phasor components of v(t) and i(t) at the mixing frequencies f_n = f_{IF} + nf_{LO} where n is an integer, are denoted by V and I, respectively), see Fig. 18. V and I are related by means of a conversion matrix Y_j, I = Y_jV = (G_j + jΩC_j)V, see the notation used in [6] and [29].
- The impedance of the diode at the different mixing frequencies and the conversion losses of the mixer can be directly evaluated with the conversion matrix. At the IF frequency, the output impedance of the diode can be found by setting a signal source at the IF frequency, and calculating [29]

$$Z_{\text{out}}(f_{\text{IF}}) = \frac{V_s(f_{\text{IF}})}{I_{\text{IF}}} - Z_e(f_{\text{IF}}), \tag{9}$$

where $V_s(f_{\rm IF})$ is the small-signal voltage source at frequency $f_{\rm IF}, I_{\rm IF}$ is the current phasors at $f_{\rm IF}$ and $Z_e(f_{\rm IF})$ is the impedance of the circuit at $f_{\rm IF}, Z_{\rm out}(f_{\rm IF})$ is equivalent to the definition of $Z_{d,\rm SS}(f_{\rm IF})$ in (5). These impedances, $Z_{\rm out}(f_{\rm IF})$ and $Z_{d,\rm SS}(f_{\rm IF})$, represent the small-signal impedance seen at the terminals of the diode in the mixer circuit at frequency $f_{\rm IF}$, see Fig. 18.

 Noise is a small-signal phenomenon. So, the conversion matrix formalism together with analytical models for shot, thermal and hot electron noise contributions are used to

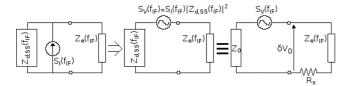


Fig. 19. The transformation of the current noise source at $f_{\rm IF}$ in parallel with the small-signal impedance $Z_{d,\rm SS}(f_{\rm IF})$ to an equivalent voltage noise source in series with $Z_{d,\rm SS}(f_{\rm IF})$ by means of Thévenin's theorem.

calculate the noise correlation matrices and evaluate the equivalent input noise temperature of the mixer. Let $\delta I_m'$ denote the phasor of the noise current at each mixing frequency f_m , see Fig. 18. The noise correlation matrices of the different noise sources can be found in the literature [6], [15], [29].

• The noise power delivered to the output load at IF frequency is [29]

$$P_{\text{del}}(f_{\text{IF}}) = \frac{\langle |\delta V_0|^2 \rangle \text{Re}\{Z_e(f_{\text{IF}})\}}{|Z_e(f_{\text{IF}}) + R_s|^2}.$$
 (10)

where $\langle |\delta V_0|^2 \rangle$ is the total mean-squared noise voltage at $f_{\rm IF}$ [6], [29], [36]. This equation is equivalent to (7) used in the MC simulations. Using Thévenin's theorem in the circuit of Fig. 3, the equivalent circuit of the noisy diode at IF frequency can be represented by a voltage noise source characterized by $S_V(f_{\rm IF}) = S_I(f_{\rm IF})|Z_{d,\rm SS}(f_{\rm IF})|^2$ in series with $Z_{d,\rm SS}$, see Fig. 19. Using this transformation in (7), the noise power delivered to the output load $Z_e(f_{\rm IF})$ is

$$P_{\text{del}}(f_{\text{IF}}) = \frac{S_V(f_{\text{IF}})\Delta f \text{Re}\{Z_e(f_{\text{IF}})\}}{|Z_{d,\text{SS}}(f_{\text{IF}}) + Z_e(f_{\text{IF}})|^2}.$$
 (11)

In the CM formalism with a LEC model of the diode, $Z_{\rm out}(f_{\rm IF})=Z_0+R_s$ where Z_0 is the impedance defined in Fig. 18 at IF frequency [6]. Equation (10) is expressed in terms of δV_0 , i.e., the voltage fluctuations in the series combination of R_s and $Z_e(f_{\rm IF})$, see Fig. 18. In the circuit of Fig. 19, the small-signal impedance $Z_{d,\rm SS}(f_{\rm IF})$ can be expressed as $Z_{d,\rm SS}(f_{\rm IF})\equiv Z_{\rm out}(f_{\rm IF})=Z_0+R_s$ and the voltage noise spectral density can be written as $S_V(f_{\rm IF})\Delta f=\langle |\delta V_{\rm ns,0}|^2 \rangle$. According to Fig. 19, δV_0 and $\delta V_{\rm ns,0}$ are related by

$$\delta V_{\rm ns,0} = \frac{Z_0 + R_s + Z_e(f_{\rm IF})}{Z_e(f_{\rm IF}) + R_s} \delta V_0$$

$$= \frac{Z_{d,\rm SS}(f_{\rm IF}) + Z_e(f_{\rm IF})}{Z_e(f_{\rm IF}) + R_s} \delta V_0. \tag{12}$$

 $S_V(f_{\rm IF})\Delta f = \langle |\delta V_{\rm ns,0}|^2 \rangle$ can be written in terms of δV_0 by using (12). When this expression of $S_V(f_{\rm IF})$ is used in (11), we recover (10).

REFERENCES

- [1] T. W. Crowe, W. L. Bishop, D. W. Porterfield, J. L. Hesler, I. Weikle, and R. M., "Opening the terahertz window with integrated diode circuits," *IEEE J. Solid-State Circuits*, vol. 40, no. 10, pp. 2104–2110, Oct. 2005.
- [2] P. Siegel, "THz instruments for space," *IEEE Trans. Antennas Propag.*, vol. 55, no. 11, pp. 2957–2965, Nov. 2007.

- [3] G. Chattopadhyay, "Technology, capabilities, and performance of low power terahertz sources," *IEEE Trans. THz Sci. Technol.*, vol. 1, no. 1, pp. 33–53, Sep. 2011.
- [4] P. H. Siegel, "Terahertz technology," *IEEE Trans. Microw. Theory Techn.*, vol. 50, no. 5, pp. 910–928, Mar. 2002.
- [5] A. Maestrini et al., "Schottky diode-based terahertz frequency multipliers and mixers," C. R. Phys., vol. 11, no. 7-8, pp. 480–495, Aug. 2010.
- [6] D. Held and A. Kerr, "Conversion loss and noise of microwave and millimeterwave mixers: Part I—Theory," *IEEE Trans. Microw. Theory Techn.*, vol. MTT-26, no. 2, pp. 49–55, Feb. 1978.
- [7] K. Champlin and G. Eisenstein, "Cutoff frequency of submillimeter Schottky-barrier diodes," *IEEE Trans. Microw. Theory Techn.*, vol. MTT-26, no. 1, pp. 31–34, Jan. 1978.
- [8] T. W. Crowe, "GaAs Schottky barrier mixer diodes for the frequency range 1–10 THz," Int. J. Infrared Millim. Waves, vol. 10, no. 7, pp. 765–777, Jul. 1989.
- [9] E. Kolberg, T. Tolmunen, M. Frerking, and J. East, "Current saturation in submillimeter-wave varactors," *IEEE Trans. Microw. Theory Techn.*, vol. 40, no. 5, pp. 831–838, May 1992.
- [10] J. East, "Monte Carlo simulation of Schottky barrier mixers and varactors," in *Proc. 6th Int. Symp. Space Terahertz Tech.*, Pasadena, California, Mar. 1995.
- [11] W. L. Schroeder and I. Wolff, "Monte-Carlo study of high-frequency, large-signal transport parameters for physics based device simulation," *IEEE Trans. Electron Devices*, vol. 42, no. 5, pp. 819–827, May 1995.
- [12] R. Lipsey et al., "Monte Carlo harmonic-balance and drift-diffusion harmonic-balance analyses of 100–600 GHz Schottky barrier varactor frequency multipliers," *IEEE Trans. Electron Devices*, vol. 44, no. 11, pp. 1843–1850, Nov. 1997.
- [13] J. Grajal, V. Krozer, E. Gonzalez, F. Maldonado, and J. Gismero, "Modeling and design aspects of millimeter-wave and submillimeter-wave Schottky diode varactor frequency multipliers," *IEEE Trans. Microw. Theory Techn.*, vol. 48, no. 4, pp. 700–711, Apr. 2000.
- [14] H. Zirath, "High-frequency noise and current-voltage characteristics of mm-wave platinum n-n+ GaAs Schottky barrier diodes," J. Appl. Phys., vol. 60, no. 4, p. 1399, 1986.
- [15] T. Crowe and R. Mattauch, "Analysis and optimization of millimeterand submillimeter-wavelength mixer diodes," *IEEE Trans. Microw. Theory Techn.*, vol. MTT-35, no. 2, pp. 159–168, Feb. 1987.
- [16] K. M. van Vliet, "Markov approach to density fluctuations due to transport and scattering. II applications," *J. Math. Phys.*, vol. 12, no. 9, pp. 1998–2012, 1971.
- [17] V. Gruzinskis, E. Starikov, P. Shiktorov, L. Reggiani, and L. Varani, "Hydrodynamic approach to noise spectra in unipolar semiconductor structures," *Appl. Phys. Lett.*, vol. 64, no. 13, pp. 1662–1664, Mar. 1994
- [18] F. Bonani and G. Ghione, Noise in Semiconductor Devices: Modeling and Simulation. Berlin, Germany: Springer-Verlag, 2001.
- [19] F. Bonani, S. Guerrieri, and G. Ghione, "Physics-based simulation techniques for small- and large-signal device noise analysis in RF applications," *IEEE Trans. Electron Devices*, vol. 50, no. 3, pp. 633–644, Mar. 2003.
- [20] M. V. Fischetti and S. E. Laux, "Monte Carlo analysis of electron transport in small semiconductor devices including band-structure and space-charge effects," *Phys. Rev. B*, vol. 38, no. 14, pp. 9721–9745, Nov. 1988.
- [21] C. Jacoboni and P. Lugli, The Monte Carlo Method for Semiconductor Device Simulation. New York, NY, USA: Springer-Verlag, 1989.
- [22] P. Shiktorov, E. Starikov, V. Gruzhinskis, S. Pérez, T. González, L. Reggiani, L. Varani, and J. C. Vaissiere, "Upconversion of partition noise in semiconductors operating under periodic large-signal conditions," *Phys. Rev. B*, vol. 67, 2003.
- [23] P. Shiktorov *et al.*, "Monte Carlo simulation of Schottky diodes operating under terahertz cyclostationary conditions," *IEEE Electron Device Lett.*, vol. 25, no. 1, pp. 1–3, Jan. 2004.
- [24] S. Pérez et al., "Noise in Schottky-barrier diodes: From static to largesignal operation," in *Proc. SPIE*, 2004, vol. 5470.
- [25] D. Pardo, "Analysis and design of multipliers and mixers via monte carlo modeling at THz bands" Ph.D. dissertation, Univ. Politécnica de Madrid, Madrid, Spain, Dec. 2014 [Online]. Available: http://oa.upm. es/33736/
- [26] C. Predmore, A. Raisanen, N. Erickson, P. Goldsmith, and J. L. Marrero, "A broad-band, ultra-low-noise Schottky diode receiver from 80 to 115 GHz diode," *IEEE Trans. Microw. Theory Techn.*, vol. 32, no. 5, pp. 498–507, May 1984.

- [27] W. Y. Ali-Ahmad, W. Bishop, T. Crowe, and G. Rebeiz, "An 86–106 GHz quasi-integrated low noise Schottky receiver," *IEEE Trans. Microw. Theory Techn.*, vol. 41, no. 4, pp. 558–564, Apr. 1993.
- [28] B. Thomas, "Etude et realisation d\u00edne tete de reception heterodyne en ondes submillimetriques pour letude des atmospheres et surfaces de planetes," Ph.D. dissertation, Laboratoire d\u00e9tude du Rayonnement et de la Matiere en Astrophysique, Observatoire de Paris, , Dec. 2004.
- [29] S. Maas, Microwave Mixers, 2nd ed. Boston, MA: Artech House, 1993.
- [30] M. Lundstrom, Fundamentals of Carrier Transport, 2nd ed. Cambridge, U.K.: Cambridge Univ. Press, 2000.
- [31] T. González, D. Pardo, L. Reggiani, and L. Varani, "Microscopic analysis of electron noise in GaAs Schottky barrier diodes," *J. Appl. Phys.*, vol. 82, no. 5, pp. 2349–2358, 1997.
- [32] J.-P. Nougier, "Fluctuations and noise of hot carriers in semiconductor materials and devices," *IEEE Trans. Electron Devices*, vol. 41, no. 11, pp. 2034–2049, 1994.
- [33] D. Pardo, J. Grajal, S. Pérez, B. Mencía, J. Mateos, and T. González, "Analysis of noise spectra in GaAs and GaN Schottky barrier diodes," *Semicond. Sci. Technol.*, vol. 26, no. 5, p. 055023, 2011.
- [34] J. Hesler et al., "Fixed-tuned submillimeter wavelength waveguide mixers using planar Schottky-barrier diodes," *IEEE Trans. Microw. Theory Techn.*, vol. 45, no. 5, pp. 653–658, May 1997.
- [35] K. Kundert, G. Sorkin, and A. Sangiovanni-Vincentelli, "Applying harmonic balance to almost-periodic circuits," *IEEE Trans. Microw. Theory Techn.*, vol. 36, no. 2, pp. 366–378, Feb. 1988.
- [36] S. Maas, Nonlinear Microwave Circuits. Reading, MA, USA: Artech House, 1988, Incorporated.
- [37] P. J. C. Rodrigues, Computer-Aided Analysis of Nonlinear Microwave Circuits. Boston, MA, USA: Artech House, 1997.
- [38] X.-D. Zhang, X.-N. Hong, and B.-X. Gao, "An accurate Fourier transform method for nonlinear circuits analysis with multi-tone driven," IEEE Trans. Circuits Syst., vol. 37, no. 5, pp. 668–669, May 1990.
- [39] A. Van der Ziel, Noise; Sources, Characterization, Measurement. Englewood Cliffs, NJ, USA: Prentice-Hall, 1970.
- [40] W. Gardner, "Signal interception: A unifying theoretical framework for feature detection," *IEEE Trans. Commun.*, vol. 36, no. 8, pp. 897–906, Aug. 1988.
- [41] M. Trippe, G. Bosman, and A. van der Ziel, "Transit-time effects in the noise of Schottky-barrier diodes," *IEEE Trans. Microw. Theory Techn.*, vol. MTT-34, no. 11, pp. 1183–1192, Nov. 1986.
- [42] J. L. Hesler, "Planar Schottky diodes in submillimeter-wavelength waveguide receivers," Ph.D. dissertation, University of Virginia, Blacksburg, VA, USA, Jan. 1996.
- [43] H. Torrey, C. Whitmer, and S. Goudsmit, Crystal Rectifiers. New York, NY, USA: McGraw-Hill, 1948.
- [44] E. H. Rhoderick and R. H. Williams, Metal-Semiconductor Contacts, 2nd ed. Oxford, U.K.: Clarendon, 1988.
- [45] C. Burckhardt, "Analysis of varactor frequency multipliers for arbitrary capacitance variation and drive level," *Bell Syst. Tech. J.*, vol. 44, no. 4, pp. 675–692, Apr. 1965.
- [46] W. Ali-Ahmad, "Millimeter and submillimeter-wave integrated horn antenna Schottky receivers," Ph.D. dissertation, Univ. Michigan, CAMPUS???, 1993.
- [47] B. Thomas, A. Maestrini, and G. Beaudin, "A low-noise fixed-tuned 300–360 GHz sub-harmonic mixer using planar Schottky diodes," *IEEE Microw. Wireless Compon. Lett.*, vol. 15, no. 12, pp. 865–867, Dec. 2005.
- [48] B. Thomas et al., "An 874 GHz fundamental balanced mixer based on MMIC membrane planar Schottky diodes," in Proc. 21st Int. Symp. Space Terahertz Tech., Oxford, UK, Mar. 2010.
- [49] B. Thomas et al., "A broadband 835–900 GHz fundamental balanced mixer based on monolithic GaAs membrane Schottky diodes," *IEEE Trans. Microw. Theory Techn.*, vol. 58, no. 7, pp. 1917–1924, Jul. 2010.
- [50] B. Thomas and J. Siles et al., "560 GHz, 664 GHz and 1.2 THz Schottky based MMIC sub-harmonic mixers for planetary atmospheric remote sensing and FMCW radar," in *Proc. 22rd Int. Symp. Space THz Tech.*, Tucson, AZ, Apr. 2011, pp. 139–142.
- [51] E. Schlecht et al., "Schottky diode based 1.2 THz receivers operating at room-temperature and below for planetary atmospheric sounding," *IEEE Trans. THz Sci. Technol.*, vol. 4, no. 6, pp. 661–669, Nov. 2014.
- [52] P. H. Siegel, R. P. Smith, M. C. Graidis, and S. C. Martin, "2.5 THz GaAs monolithic membrane-diode mixer," *IEEE Trans. Microw. Theory Techn.*, vol. 47, pp. 596–604, May 1999.

- [53] A. Betz and R. Boreiko, "A practical Schottky mixer for 5 THz (Part II)," in *Proc. 7th Int. Symp. Space Terahertz Tech.*, Mar. 1996, p. 503.
- [54] K. Hui, J. Hesler, D. Kurtz, W. Bishop, and T. Crowe, "A micromachined 585 GHz Schottky mixer," *IEEE Microw. Guided Wave Lett.*, vol. 10, no. 9, pp. 374–376, Sept. 2000.
- [55] B. Thomas, A. Maestrini, D. Matheson, I. Mehdi, and P. de Maagt, "Design of an 874 GHz biasable sub-harmonic mixer based on MMIC membrane planar Schottky diodes," in *Proc. 33rd Int. Conf. Infrared, Millim., and THz Waves*, Sep. 2008, pp. 1–2.
- [56] T. Crowe, R. Mattauch, H. Roser, W. Bishop, W. Peatman, and X. Liu, "GaAs Schottky diodes for THz mixing applications," *Proc. IEEE*, vol. 80, no. 11, pp. 1827–1841, Nov. 1992.
- [57] S. Maas, Noise in Linear and Nonlinear Circuits. : Artech House, 2005.
- [58] H. Wang, S. Jones, G. Tait, and C. Mann, T. W. Crowe and R. M. Weikle, Eds., "Combined circuit-device time domain simulation of 2.5 THz GaAs Schottky diode mixers," in *Proc. 10th Int. Symp. Space THz Tech.*, Mar. 1999, p. 419.
- [59] J. Siles, J. Grajal, and A. Di Carlo, "Design of submillimeter Schottky mixers under flat-band conditions using an improved drift-diffusion model," *IEEE Microw. Wireless Compon. Lett.*, vol. 19, no. 3, pp. 167–169, Mar. 2009.
- [60] G. Hegazi, A. Jelenski, and K. Yngvesson, "Limitations of microwaveand millimeter-wave mixers due to excess noise," *IEEE Trans. Microw. Theory Techn.*, vol. 33, no. 12, pp. 1404–1409, Dec. 1985.



Diego Pardo was born in Salamanca, Spain, in 1984. He received the degree in theoretical physics from the Universidad de Salamanca, Salamanca, Spain, in 2008, and the Ph.D. degree from the Universidad Politécnica de Madrid, Madrid, Spain, in 2014.

Since 2009, he has been with the Signals, System, and Radiocommunications Department at Technical University of Madrid, Madrid, Spain. His research activities are in the area of semiconductor device modeling, including physic-based noise analysis.



Jesús Grajal was born in Toral de los Guzmanes (León), Spain, in 1967. He received the Ingeniero de Telecomunicación degree and the Ph.D. degree from the Universidad Politécnica de Madrid, Madrid, Spain, in 1992 and 1998, respectively.

In 1993, he joined the Signal, System, and Radiocommunications Department at Technical University of Madrid, Madrid, Spain, where he has been an Associate Professor since 1998. His research activities are in the area of semiconductor device modeling and high-frequency circuit and system design.

Dr. Grajal was a co-recipient of the 2013 EuCAP best antenna design paper award.



Susana Pérez was born in Salamanca, Spain, in 1970. She received the M.S. degree in physics and the Ph.D. degree in physics from the Universidad de Salamanca, Salamanca, in 1993 and 1999, respectively.

Since 1994, she has been with the Applied Physics Department, Universidad de Salamanca, Salamanca, Spain, where she became an Associate Professor in 2009. She was a Visiting Researcher with the LCR of Thomson-CSF (Thales), Orsay, France, and with the IRCOM (Xlim), Limoges, France. Her current re-

search interests are in the development of terahertz devices and the field of numerical simulation of electronic transport and noise in submicrometer semiconductor devices.